

Contribution ID: 43 Type: Talk

Chemical etching of silicon by nanostructured metal catalyst for fabrication of high aspect ratio gratings

Tuesday 12 September 2017 11:30 (20 minutes)

Author: Prof. ROMANO, Lucia (PSI)

Co-authors: Dr VILA-COMAMALA, Joan (Institute for Biomedical Engineering); Dr JEFIMOVS, Konstantins

(PSI); STAMPANONI, Marco (Paul Scherrer Institut)

Presenter: Prof. ROMANO, Lucia (PSI)

Session Classification: Fabrication Methods

Track Classification: Fabrication Methods